



HAL
open science

Model of steady-state ultrafiltration of colloidal suspension with formation of non-Newtonian concentration polarization layer and compressible deposit under laminar cross-flow

Hossein Gholamian, Maksym Loginov, Geneviève Gésan-Guiziou

► To cite this version:

Hossein Gholamian, Maksym Loginov, Geneviève Gésan-Guiziou. Model of steady-state ultrafiltration of colloidal suspension with formation of non-Newtonian concentration polarization layer and compressible deposit under laminar cross-flow. FILTECH 2023, Feb 2023, Cologne, Germany. , 2023. hal-04001740

HAL Id: hal-04001740

<https://hal.inrae.fr/hal-04001740>

Submitted on 23 Feb 2023

HAL is a multi-disciplinary open access archive for the deposit and dissemination of scientific research documents, whether they are published or not. The documents may come from teaching and research institutions in France or abroad, or from public or private research centers.

L'archive ouverte pluridisciplinaire **HAL**, est destinée au dépôt et à la diffusion de documents scientifiques de niveau recherche, publiés ou non, émanant des établissements d'enseignement et de recherche français ou étrangers, des laboratoires publics ou privés.



Distributed under a Creative Commons Attribution - NonCommercial - NoDerivatives 4.0 International License

Model of steady-state ultrafiltration of colloidal suspension with formation of non-Newtonian concentration polarization layer and compressible deposit under laminar cross-flow

Maksym Loginov*, Hossein Gholamian, Geneviève Gésan-Guiziou
UMR 1253 STLO, INRAE – Institut Agro, Rennes, France

- We extended approach of Gaddis (1992) and Bacchin et al. (2002) to model the cross-flow filtration of real colloidal suspensions
- Our model accounts for actual rheological properties of the system (either Newtonian or non-Newtonian concentration polarization layer), as well as local compressibility and permeability of the concentration polarization layer and the deposit
- The local filtrate flux and the local concentration polarization layer/ the local deposit structure can be calculated for given concentration of suspension, transmembrane pressure, and applied wall shear stress
- However, the model application is limited to the case of the laminar cross-flow filtration with fully retentive membrane and relatively thin concentration-polarization layer (as compared to the hydraulic diameter of the filter channel)
- All equations can be found in the extended abstract in the electronic version of Filtech 2023 proceedings; an example of the model application can be found in Loginov et al., *Journal of Membrane Science*, 2021; for everyone's convenience main model equations are provided below**



*Dear friend, if you know where to find a single channel ceramic membrane with the inner diameter of 4 mm or less, please, let me know. Thank you! Maksym maksym.loginov@inrae.fr

**Same thing, now with equations

Model accounts for (a) local cross-flow transport of particles that depends on local particle concentration and local cross-flow velocity

$$Q_0 \phi_0 = 2\pi R \int_{h_d(x)}^{h_{cp}(x)+h_d(x)} u(x,z) (\phi(x,z) - \phi_0) dz + Q(x) \phi_0$$

(b) local cross-flow velocity that depends on local *rheological properties* and local shear stress

$$u(x,z) = \int_{h_d(x)}^z \dot{\gamma}(\phi,\tau) dz$$

(c) and local filtrate flux that depends on local *compressibility and permeability*

$$\mu_f J(x) = -k(x,z) \frac{d\Pi(x,z)}{dz}$$

Combination of these equations yields

$$Q(x) = Q_0 - \frac{2\pi R}{\phi_0 \mu_f^2 J(x)^2} \int_{\phi_0}^{\phi_{sg}} (\phi - \phi_0) k(\phi) \frac{\partial \Pi(\phi)}{\partial \phi} \left[\int_{\phi}^{\phi_{sg}} \dot{\gamma}(\phi,\tau) k(\phi) \frac{\partial \Pi(\phi)}{\partial \phi} d\phi \right] d\phi$$

that describes the mass balance over the membrane covered with the deposit, and

$$Q(x) = Q_0 - \frac{2\pi R}{\phi_0 \mu_f^2 J(x)^2} \int_{\phi_0}^{\phi_w(x)} (\phi - \phi_0) k(\phi) \frac{\partial \Pi(\phi)}{\partial \phi} \left[\int_{\phi}^{\phi_w(x)} \dot{\gamma}(\phi,\tau) k(\phi) \frac{\partial \Pi(\phi)}{\partial \phi} d\phi \right] d\phi$$

that is applied, where there is no deposit on the membrane surface.

Each of these mass balance equations can be combined with

$$\frac{dQ(x)}{dx} = -2\pi R J(x)$$

that relates local cross-flow and filtrate flux,

$$\mu_f R_m J(x) = P(x) - \Pi(\phi_w(x)) - P_f(x)$$

that relates local filtrate flux and local pressure balance, and

$$P(x) = P_0 - \frac{2\tau}{R} x$$

that is the local pressure variation along the filter channel.

Combination of four last equations yields ordinary differential equation

$$\frac{d\phi_w}{dx} = \frac{-\frac{\phi_0}{\mu_f R_m^2} \left[P_0 - \frac{2\tau}{R} x - \Pi(\phi_w) \right]^4 - \frac{4\tau}{R} M(\phi_w, \tau)}{\left[P_0 - \frac{2\tau}{R} x - \Pi(\phi_w) \right] \frac{dM(\phi_w, \tau)}{d\phi_w} + 2M(\phi_w) \frac{d\Pi(\phi_w)}{d\phi_w}}$$

that can be solved numerically for given colloidal object (filtered suspension), i.e., for known *rheological properties, compressibility and permeability*. Obtained dependency of $\phi_w(x)$ is used to calculate $J(x)$.

In the area, where $\phi_w(x) > \phi_{sg}$ (the membrane is covered with the deposit) the local filtrate flux is calculated as

$$J(x) = \left[J^{-3}(x_{cr1}) + \frac{3\phi_0 \mu_f^2}{2M(\phi_{sg}, \tau)} (x - x_{cr1}) \right]^{\frac{1}{3}}$$

The local variable M is defined as

$$M(\phi_w, \tau) = \int_{\phi_0}^{\phi_w} (\phi - \phi_0) k(\phi) \frac{\partial \Pi(\phi)}{\partial \phi} \left[\int_{\phi}^{\phi_w} \dot{\gamma}(\phi, \tau) k(\phi) \frac{\partial \Pi(\phi)}{\partial \phi} d\phi \right] d\phi$$

when the deposit is not on the membrane surface, and

$$M(\phi_{sg}, \tau) = \int_{\phi_0}^{\phi_{sg}} (\phi - \phi_0) k(\phi) \frac{\partial \Pi(\phi)}{\partial \phi} \left[\int_{\phi}^{\phi_{sg}} \dot{\gamma}(\phi, \tau) k(\phi) \frac{\partial \Pi(\phi)}{\partial \phi} d\phi \right] d\phi$$

when it is.

Among other things, it means, that the steady-state filtration kinetics is not governed by deposit properties.

NOMENCLATURE

h_{cp} local thickness of CP layer (m)

h_d local thickness of deposit (m)

J local filtrate flux ($m \cdot s^{-1}$)

k local permeability (m^2)

M filterability, material function that governs cross-flow filtration ($m^4 \cdot Pa^2 \cdot s^{-1}$)

P total pressure in the filtration channel (Pa)

P_0 total pressure at the entrance to the filter channel (Pa)

P_f pressure at filtrate side (Pa)

Q average tangential flow rate in the filter channel ($m^3 \cdot s^{-1}$)

Q_0 average tangential flow rate at the entrance to the filter channel ($m^3 \cdot s^{-1}$)

R inner radius of filter channel (m)

R_m membrane resistance (m^{-1})

u local tangential flow rate ($m \cdot s^{-1}$)

x axial distance from the entrance of the filter channel (m)

x_{cr1} first critical distance, axial distance from the entrance of the filter channel, where the deposit appears on the membrane surface (m)

z normal distance from the membrane surface (m)

GREEK LETTERS

γ local shear rate (s^{-1})

μ_f filtrate viscosity (Pa·s)

Π local osmotic pressure of particles in CP layer or solid pressure in deposit (Pa)

τ shear stress, wall shear stress (Pa)

ϕ particle volume fraction (dimensionless)

ϕ_0 particle volume fraction in feed suspension (dimensionless)

ϕ_{sg} particle volume fraction in point of sol-gel transition (dimensionless)

ϕ_w particle volume fraction on the membrane surface (dimensionless)